

L Number	Hits	Search Text	DB	Time stamp
1	616	NITROXYL WITH RADICAL	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:16
2	149714	\$3cvd or (chemical adj vapor adj deposition)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:13
3	2	(NITROXYL WITH RADICAL) same (\$3cvd or (chemical adj vapor adj deposition))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:15
4	1	2002-123531.NRAN.	DERWENT	2003/10/16 16:14
5	4	(NITROXYL WITH RADICAL) and (\$3cvd or (chemical adj vapor adj deposition))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:15
6	2	((NITROXYL WITH RADICAL) and (\$3cvd or (chemical adj vapor adj deposition))) not ((NITROXYL WITH RADICAL) same (\$3cvd or (chemical adj vapor adj deposition)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:15
7	1055	NITROXYL	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:16
8	2	NITROXYL same (\$3cvd or (chemical adj vapor adj deposition))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:16
9	6	NITROXYL and (\$3cvd or (chemical adj vapor adj deposition))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/10/16 16:16